

# Cross-sectional EBSD analysis of wire bonding inside a package located by XRM

The layout of chips and wires inside a semiconductor package cannot be determined from the outside. Examples of XRM observation for wire bonding positions inside a package and the following cross-sectional processing and EBSD analysis are shown.

## 1. Observation of the inside of a package by XRM

XRM: X-Ray Microscope, EBSD: Electron Back-Scattering Diffraction

### Identification of wire bonding location by XRM.

→ Cross-sectional processing at the center of the wire bonding.

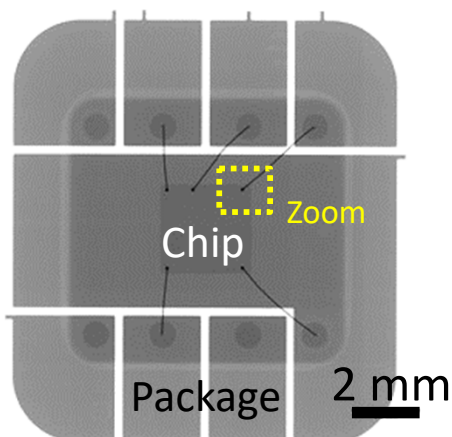


Fig.1. Top-view XRM images of the semiconductor package

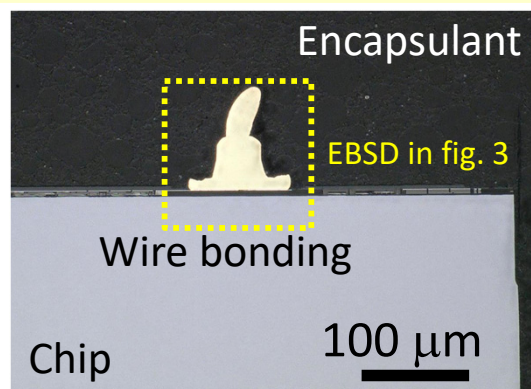
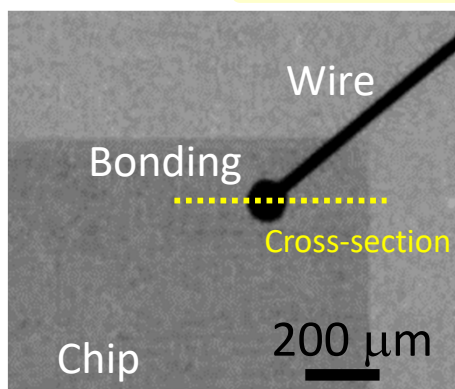
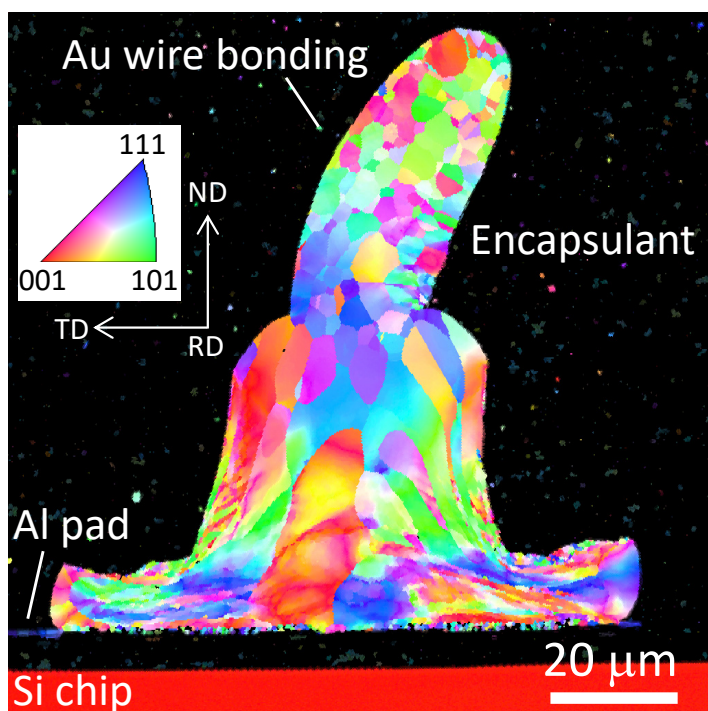


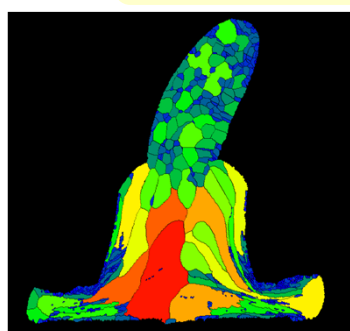
Fig.2. The cross-sectional optical microscope image

## 2. Cross-sectional EBSD analysis of the wire bonding

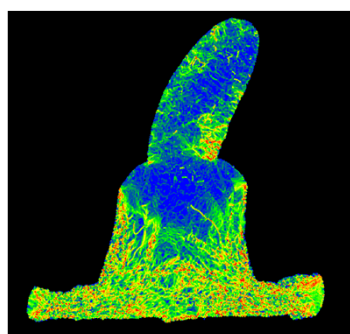
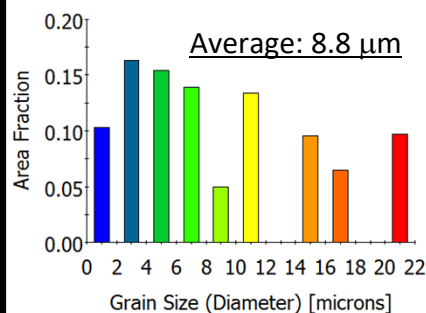
EBSD analysis → grain size distribution and KAM map related to plastic deformation.



(a) The crystal orientation map (ND)



(b) The grain-size map and chart



(c) The KAM map and chart

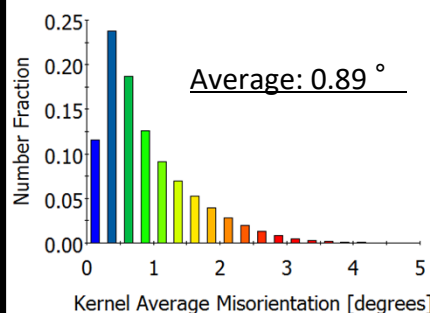


Fig.3. Results of the EBSD analysis. (a) The crystal orientation map along normal direction (ND), (b) The grain-size map and chart, (c) The kernel average misorientation (KAM) map and chart according to plastic strain

The internal structure of a sample can be observed by XRM!

The degree and distribution of plastic deformation can be evaluated using EBSD!